

IFW

Attorney's Docket No. 035576/271460

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Iwabuchi et al.

Confirmation No.: 6716

Appl. No.: 10/706,863

Filed: 11/12/2003

For: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM
AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR
FILM, AND SEMICONDUCTOR DEVICE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

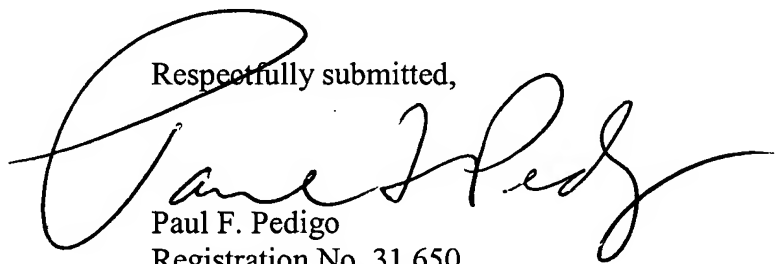
INFORMATION DISCLOSURE STATEMENT
CITATION UNDER 37 C.F.R. § 1.97

Sir:

Attached is a list of documents on form PTO-1449, along with any cited foreign patent documents and non-patent literature documents in accordance with 37 CFR 1.98(a)(2).

It is requested that the Examiner consider these documents and officially make them of record in accordance with the provisions of 37 C.F.R. § 1.97 and Section 609 of the MPEP. By identifying the listed documents, Applicant in no way makes any admission as to the prior art status of the listed documents, but is instead identifying the listed documents for the sake of full disclosure.

Respectfully submitted,

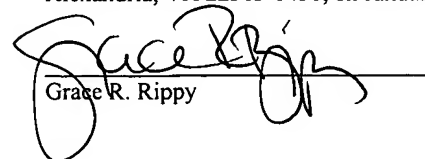


Paul F. Pedigo
Registration No. 31,650
Registration No. 31,650

Customer No. 00826
ALSTON & BIRD LLP
Bank of America Plaza
101 South Tryon Street, Suite 4000
Charlotte, NC 28280-4000
Tel Charlotte Office (704) 444-1000
Fax Charlotte Office (704) 444-1111

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450, on January 4, 2005.



Grace R. Rippy

Substitute for form 1449/PTO (Revised 04/2003) INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(Use as many sheets as necessary)</i>				Complete if Known	
				Application Number	10/706,863
				Filing Date	11/12/2003
				First Named Inventor	Iwabuchi et al.
				Group Art Unit	
Examiner Name					
Attorney Docket Number	035576/271460				
Sheet	1	of	1		

U. S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.	Document Number Number - Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages of Relevant Figures Appear
	1	US-6,639,015	10/28/2003	Nakashima et al.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document Country Code - Number Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	English Language Translation Attached
	2	JP 2001-002993	01/09/2001	JSR Corp.	English Abstract	
	3	JP 2001-98218	04/10/2001	Hitachi Chem. Co., Ltd.	English Abstract	
	4	JP 2001-115021	04/24/2001	Asahi Kasei Corp.	English Abstract	
	5	JP 2001-131479	05/15/2001	Tokyo Ohka Kogyo Co., Ltd.	English Abstract	
	6	JP 2001-080915	03/27/2001	Matsushita Electric Ind Co Ltd	English Abstract	
	7	WO 00/12640	03/09/2000	Catalysts & Chemicals Industries Co., Ltd.	English Abstract	
	8	JP 2001-55554	02/27/2001	JSR Corp.	English Abstract	
	9	JP 6-145599	05/24/1994	Toray Industries, Inc.	English Abstract	
	10	EP 1223192	07/17/2002	Shin-Etsu Chemical Co., Ltd.	English Abstract	
	11	JP 2002-23354	01/23/2002	Shin-Etsu Chemical Co., Ltd.	English Abstract	

OTHER DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	English Language Translation Attached
	12	International Search Report From International Application Number PCT/JP03/14438 dated December 15, 2003	

Examiner Signature		Date Considered	
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*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.